## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)		
	)		
Yongren Benjamin PENG, et al.	)	Art Unit:	TBA
	)		
Application Number: 10/531,996	)	Examiner:	Unassigne
	)		
Filed April 20, 2005	i	Confirmation	n No : TB/

For: PARTICULATE MATERIALS AND COMPOSITIONS FOR RADIOTHERAPY

## INFORMATION DISCLOSURE STATEMENT

MAIL STOP AMENDMENT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. §§ 1.97 and 1.98, and in compliance with the duty of disclosure set forth in 37 C.F.R. § 1.56, Applicants are submitting herewith copies of the references other than U.S. patents and U.S. patent publications listed on the attached Form PTO/SB/08A (modified) for consideration and request the documents cited therein be made of record by the U.S. Patent and Trademark Office in the above-captioned application.

Two of the cited documents were cited by the United States Patent and Trademark Office in the International Search Report and Written Opinion of the International Searching Authority dated July 11, 2005 for International Application No. PCT/US05/07201, which was filed on March 7, 2005. A copy of the International Search Report and Written Opinion of the International Searching Authority is enclosed herein.

Consideration of the foregoing plus the prompt return of a copy of the enclosed Form PTO/SB/08A with the Examiner's initials in the left column in accordance with M.P.E.P. § 609 are respectfully requested.

Applicants respectfully point out that the submission of the listed documents in this Information Disclosure Statement is not an admission that they are prior art or that they are material to patentability of any claims of the application. Also, the submission of this Information Disclosure Statement is not an indication that a search has been made by Applicants.

For the convenience of the Examiner in considering the cited documents, a copy of each of the cited documents other than U.S. patents and U.S. patent publications is enclosed with this communication. In considering the cited documents, it may be noted by the Examiner that certain of the documents may contain markings, underlinings, and/or other notations. These markings, underlinings, and/or other notations are not to be construed as drawing the Examiner's attention either to selected parts or away from other parts of the cited documents. Any such markings were either present on the copies of the cited documents obtained by the associated individuals, or were made thereon during the study of the documents by the associated individuals.

In accordance with 37 C.F.R. § 1.97(b), this Information Disclosure Statement is believed to be submitted prior to issuance of a first Office Action. Therefore, it is respectfully submitted that no fee is required for consideration of this information. However, in the event any fee is deemed necessary, the Commissioner is authorized to charge the undersigned's Deposit Account No. 50-0206.

By:

Respectfully submitted,

HUNTON & WILLIAMS LLP

Dated: August 16, 2005

Robert M. Schulman

Registration No. 31,196

Alexander H. Spiegler Registration No. 56,625

Hunton & Williams LLP Intellectual Property Department 1900 K Street, N.W. Suite 1200 Washington, DC 20006 (202) 955-1500 (telephone) (202) 778-2201 (facsimile) RMS/AHS:sac Receipt date: 04/16/2005

1 062

Cheet

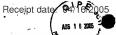
PTO/SB/08A (08/03) (modified)

## Substitute for form 1449A/PTO REPORT TO SURFAMENT BY APPLICANT (LIES AS MAIN SHOPE STATEMENT BY EACH STATEMENT BY EACH

U.S. Patent and Tradema	AMORICO, U.S. DEPARTMENT OF COMMERC		
Application Number	10/531,996		
Filing Date	April 20, 2005		
First Named Inventor	Yongren Benjamin PENG, et al.		
Art Unit	TBA		
Examiner Name	TBA		
Attorney Docket Number	58768 000007		

Sheet		1 of 2	Attorney	Docket Number 58768.0	10007	
			J.S. PATENT DO	CUMENTS		
Experience charles	Cite No.	DOCUMENT NUMBER Number - Kind Code (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages o Relevant Figures Appear	
		US- 4,789,501	12/06/1988	Day et al.		
		US- 5,011,677	04/03/1991	Day et al.		
	7	US- 6,379,648	04/30/2002	Day et al.		
		US- 6,537,518	03/25/2003	Gray, B.		
		US- 6,589,502	07/08/2003	Coniglione et al.		
		US- 6,716,156	04/06/2004	Menuhr et al.		
		US- 6,746,661	06/08/2004	Kaplan, E.		
	П	US- US 2004/0042582	03/04/2004	Ein-Gal, M.		
		US- US 2004/0197264	10/07/2004	Schwarz et al.		
		US- US 2004/0228794	11/18/2004	Weller et al.		
	Т	US- US 2004/0258614	12/23/2004	Line et al.		
		US-				
		US-				
		US-				
		US-				
		US-				
		US-				
		US-				
		US-				
		US-				
		US-				
		US-				
	Г	US-				
	Г	US-				

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



PTO/SE/08A (08/03) (modified)
Office; U.S. DEPARTMENT OF COMMERCE U.S. Patent and Tradema

		13								_	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT			Application Number Filing Date		10/531,986 April 20, 2005						
									Fà	st Named Inventor	Yongren Benjamin PENG, et al.
			51						Ar	t Unit	TBA
	(U	se as	many s	sheets as necessa.	'n	Examiner Name		TBA			
Sheet	-	20	12			Attorney Docket Number		58768.000007			
FOREIGN PATENT DOCUMENTS											
				REIGN PATENT DOCUMENT				Pages, Columns, Lines,			
"Exemplese					Bublication (	Into			TRANSLATION		
tritial tritial	CDs No.				Publication Date MM-DD-YYYY		Name of Patentee or Applicant of Cited Document	Where Relevant Passages or Relevant Figures Appear	YES	МО	
			wo	2004/050168	06/17/2004	•	Board of Regents, The University of Texas System				
										· 🗆	
		·									
					1						
	_	_			<u> </u>						
	L										
	_										
						_					
EXAMI	NER	SIGN	IATURE	/Melissa P	erreira/		DATE CONSIDERED	06/11/2009			

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.